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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: De-Ling ZHOU et al.

Confirmation No.: 4821

Serial No.: 10/689,620

Art Unit: To be assigned

Filed: October 22, 2003

Examiner: To be assigned

For: **CLEANING COMPOSITIONS  
CONTAINING HYDROXYLAMINE  
DERIVATIVES AND PROCESSES USING  
SAME FOR RESIDUE REMOVAL**

Atty. Docket No.: 60937-0140-US

**INFORMATION DISCLOSURE STATEMENT**

U.S. Patent and Trademark Office  
220 20th Street, Customer Window  
Crystal Plaza Two, Lobby, Room 1B03  
Arlington, Virginia 22202

Sir:

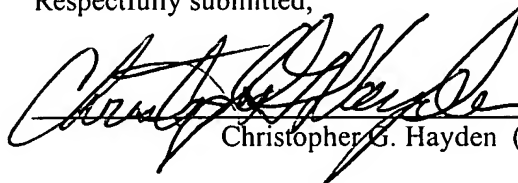
In accordance with the duty of disclosure provisions of 37 C.F.R. §1.56, there is hereby provided certain information which the Examiner may consider material to the examination of the subject U.S. patent application. It is requested that the Examiner make this information of record if it is deemed material to the examination of the application.

Enclosed with this Information Disclosure Statement is a list of all patents, publications, applications, or other information submitted for consideration by the Office. There are fourteen (14) references listed in the above-referenced application, none of which are submitted as they are included in the parent of this application. References can be provided upon request.

No fee is believed to be due for this submission, since this Information Disclosure Statement is being submitted before the first Office Action. Should any fees be required, however, please charge the required fees to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310.

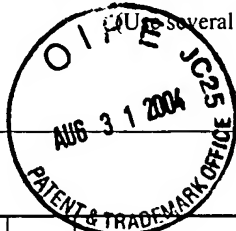
Respectfully submitted,

Date August 31, 2004

  
44,750  
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<b>LIST OF REFERENCES CITED BY APPLICANT</b> (Use several sheets if necessary)	<b>ATTY DOCKET NO.</b> 060937-0140-US	<b>APPLICATION NO</b>
	<b>APPLICANT</b> Wai Mun LEE et al.	
	<b>FILING DATE</b> June 6, 2002	<b>GROUP</b> 1746



### U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A01	4,617,251	10/1986	Sizensky			
	A02	5,997,658	12/1999	Peters et al.			
	A03	6,372,050	04/2002	Honda et al.			
	A04	6,326,130	12/2001	Schwartzkopf et al			
	A05	6,276,327	08/2001	Lee			
	A06	6,320,064	11/2001	Ofting et al.			
	A07	5,417,877	05/1995	Ward			
	A08	6,261,745	07/2001	Tanabe et al.			
	A09	5,911,835	06/1999	Lee			
	A10	5,798,323	08/198	Honda et al.			
	A11	6,268,323	07/2001	Honda et al.			

### FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	B01	1 178 359	02/2002	EPO				
	B02	2001077063	03/2001	Japan (Abstract Only)				
	B03	10321569	12/1998	Japan (Abstract Only)				
	B04							
	B05							

### OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	C01	
	C02	
	C03	

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.